



JPW

Appl. No. 10/621,497  
Preliminary Amdt. Dated January 14, 2005  
Reply to Office action of N/A

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Appl. No. : 10/621,497  
Applicant : Tetsuhiro Iwai et al.  
Filed : July 17, 2003  
Title : PLASMA PROCESSING APPARATUS AND PLASMA  
PROCESSING METHOD

Conf. No. : 2610  
TC/A.U. : 1724  
Examiner : TBD

Customer No. : 000,116  
Docket No. : 35908

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**PRELIMINARY AMENDMENT "A"**

Sir:

Please amend the above-identified application, prior to examination thereof, in the following manner.

**Amendments to the Drawings** begin on page 2 of this paper and include both an attached replacement sheet and an annotated sheet showing changes.

**Remarks/Arguments** begin on page 3 of this paper.

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to: Mail Stop Amendment, Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450 on the date indicated below.

Aaron A. Fishman

Name of Attorney for Applicant(s)

January 14, 2005

Signature of Attorney/Date